Self-supported nickel iron oxide nanospindles with high hydrophilicity for efficient oxygen evolution

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Experimental section

Preparation of NiFe₂O₄@FNF: NiFe₂O₄ nanospindle arrays were grown in situ on FNF (thickness 1 mm, YiYang Foam Metal New Material Co., Ltd) through a facile hydrothermal method. According to previous report,^{1,2} the in-situ growth can be explained by a dissolutionprecipitation mechanism. Specifically, the HCl first corrodes the surface of FeNi³ foam to Fe and Ni ions. Once the HCl is consumed completely, the generated mixed metal ions further deposit on the FeNi₃ substrate to form NiFe₂O₄ nanospindle arrays. Typically, a piece of FNF (1 cm \times 4 cm) was cleaned in 3 M HCl solution (Sigma-Aldrich, ACS reagent, 37%) and ethanol (Sigma-Aldrich, ≥99.8%) under sonication, and then rinsed with ultra-pure water for use. To prepare the hydrothermal solution, concentrated HCl was diluted with ultra-pure water until the pH of the solution was 2.5, which was measured by a pH meter (Mettler Toledo EL20-Kit Benchtop Education). 40 mL of as-prepared HCl solution was added into a 50 mL Teflon-lined stainless steel autoclave, followed by immersing the cleaned FNF into the acid solution. The autoclave was sealed and kept in a pre-heated oven at 180 °C for 6 h. After natural cooling, the product was collected and underwent ultrasonic treatment for 30 s to remove loosely attached particles. Afterwards, the product was rinsed by water and ethanol for several times, and further dried in a vacuum oven at 60 °C overnight.

Preparation of Ni(OH)₂/NF: Ni(OH)₂ nanoplate arrays supported on NF (thickness 1 mm, YiYang Foam Metal New Material Co., Ltd) were synthesized for comparison by the same procedures as for the preparation of NiFe2O4@FNF, except that the FNF was replaced with NF.

Preparation of IrO₂/NF: Commercial IrO₂ (Sigma-Aldrich, 99.9% trace metals basis) catalyst as benchmark OER electrocatalyst was loaded on NF by the same approach in previous report.³

Samples for hydrophilicity measurements: To evaluate and compare the hydrophilicity of NiFe2O4@FNF and the control groups, FeNi³ foam and Ni foam were pressed into flat plates by a roll squeezer and underwent the same hydrothermal treatment as the preparation of NiFe₂O₄@FNF and Ni(OH)₂@NF to obtain NiFe₂O₄@pFNF and Ni(OH)₂@pNF, respectively.

Material Characterizations

SEM images were collected on a Quanta 450 field-emission scanning electron microscope. TEM, SAED and HRTEM characterizations were carried out with a Tecnai $G² F30$ transmission electron microscope. XRD patterns were recorded using a Japan Rigaku MiniFlex X-ray diffractometer with graphite monochromatized Cu K α radiation (λ = 1.540598 Å). XPS spectra were acquired by an ESCALab250 XPS spectrometer.

Electrochemical Measurements

The electrochemical properties of all samples were investigated on a 760D electrochemical workstation (CH Instruments, Inc., USA) using a standard three-electrode glass cell (Pine Research Instruments, USA), in which NiFe2O4@FNF, IrO2/NF, Ni(OH)2/NF, pristine FNF and NF were used as working electrode, a carbon rod as the counter electrode, an Ag/AgCl (4 M KCl) electrode as the reference electrode, and the electrolyte was 1.0 M KOH (Sigma-Aldrich, reagent grade, 90%) aqueous solution. Prior to the electrochemical measurements, the electrolyte was purged with O_2 for 30 min to reach O_2/H_2O equilibrium at 1.23 V vs. RHE. After several CV cycling at a scan rate of 10 mV s⁻¹ to get stabilized signals, the LSV curves were collected at a scan rate of 1 $mV s^{-1}$ to evaluate the OER polarization. Chronoamperometry was adopted to study the durability in prolonged operation. CV curves in a potential window of 0.85−0.90 V vs. RHE at different

scan rates from 10 to 50 mV s^{-1} were recorded to calculate the C_{dl}. Electrochemical impedance spectroscopy (EIS) was measured at 1.50 V vs. RHE in the frequency range from 0.1 Hz to 100 kHz with an amplitude of 5 mV. All the potentials vs. Ag/AgCl were converted to a RHE scale according to the Nernst equation: $E(RHE) = E(Ag/AgCl) + 0.205 + 0.059 \times pH$, and iR correction was conducted using the solution resistance (R_s) estimated from the EIS simulation result. The apparent current density was normalized to the geometrical area of working electrode. All electrochemical measurements were performed at room temperature.

Fig. S1 SEM images of pristine FeNi³ foam.

Fig. S2 (a,b) SEM images of Ni(OH)2@NF. (c) TEM, and d) HRTEM images of corresponding Ni(OH)₂ nanoplates. The inset in panel (c) shows the SAED pattern of Ni(OH)₂ nanoplates.

Fig. S3 XRD pattern of FeNi₃ alloy foam with standard XRD pattern of FeNi₃ for reference.

Fig. S4 XRD pattern of NiFe2O4@FNF with standard XRD patterns of NiFe2O4 and FeNi3 for reference.

Fig. S5 XRD pattern of Ni(OH)2@NF with standard XRD patterns of Ni(OH)² and Ni for reference.

Fig. S6 XRD pattern of Ni foam with standard XRD pattern of Ni for reference.

Fig. S7 (a) Survey XPS spectrum, (b) Ni 2p, (c) Fe 2p, and (d) O 1s high-resolution XPS spectra of NiFe2O4@FNF.

Fig. S8 Comparison of Ni 2p high-resolution XPS spectra for NiFe₂O₄@FNF and Ni(OH)₂@NF.

Fig. S9 Comparison of O 1s high-resolution XPS spectra for NiFe₂O₄@FNF and Ni(OH)₂@NF.

Fig. S10 (a) SEM image of NiFe₂O₄@pFNF. (b) OER polarization curves of NiFe₂O₄@FNF and NiFe₂O₄@pFNF in 1.0 M KOH at a scan rate of 1 mV s⁻¹.

Fig. S11 Chronopotentiometric curve of NiFe2O4@FNF in 1.0 M KOH to deliver 10 mA cm⁻² for 100 h.

Fig. S12 (a) Ni 2p, (b) Fe 2p, and (c) O 1s high-resolution XPS spectra of NiFe₂O₄@FNF before and after OER stability test. $(d-f)$ SEM image s of NiFe₂O₄@FNF after OER stability test.

Fig. S13 CV curves of (a) NiFe₂O₄@FNF, (b) Ni(OH)₂@NF, (c) FNF, and (d) NF in a potential window of 0.85–0.90 V vs. RHE without faradaic processes at scan rates from 10 to 50 mV s⁻¹.

Table S1. Comparison of NiFe2O⁴ based OER electrocatalysts in alkaline electrolyte.

Table S2. Comparison of recently reported earth-abundant electrocatalysts for the OER in alkaline electrolyte.

Sample	Double-layer capacitance $(C_{\rm dl}, \mu F \, \rm cm^{-2})$	Roughness factor $(R_i)^a$	j @ 1.50 V vs. RHE $(mA cm^{-2})$	$j_{specific}$ @ 1.50 V vs. RHE $(mA cm-2)b$
NiFe ₂ O ₄ @FNF	946.95	15.78	15.93	1.009
$Ni(OH)_2@NF$	799.77	13.33	1.56	0.117
FNF	490.46	8.17	0.309	0.038
NF	467.8	7.80	0.208	0.027

Table S3. Electrochemical analysis of NiFe2O4@FNF, Ni(OH)2@NF, FNF and NF.

^aAccording to previous report,³² the C_{dl} of an ideal flat electrode is ~60 μ F cm⁻². R_f is therefore calculated using $R_f = \frac{C_{\text{dl}}}{60}$ $\frac{6d_1}{60} \times 1000.$

^b/_{specific} is calculated using $j_{\text{specific}} = \frac{j}{R}$ $\frac{f}{R_f}$, where *j* is the apparent OER current density.

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